



Photocatalytic degradation of EDTA with UV/Cu(II)/H₂O₂ process

Peng Liu^a, Chaolin Li^{a,*}, Xianghan Kong^a, Gang Lu^b, Jianhui Xu^a, Fei Ji^a,
Xingang Liang^a

^aEnvironmental Science & Engineering Research Center, Harbin Institute of Technology Shenzhen Graduate School, Shenzhen 518055, P.R. China

Tel. +86 755 26032455; Fax: +86 755 26032455; email: lichaolin@hitsz.edu.cn

^bDepartment of Environmental Engineering, Jinan University, Guangzhou 510632, P.R. China

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ABSTRACT

In this study, degradation of ethylene diamine tetraacetic acid (EDTA) solution by the UV/Cu(II)/H₂O₂ process under various conditions was evaluated via chemical oxygen demand (COD) removal. The reactions were performed in a lab-scale batch photoreactor. The effects of different parameters such as H₂O₂ dosage, copper catalyst dosage, initial pH, and initial EDTA concentration on the oxidation efficiency of the process were investigated. The results indicated that the UV/Cu(II)/H₂O₂ process could effectively remove COD in both synthesized EDTA wastewater and real copper-plating wastewater. According to the experimental results, a reasonable mechanism was proposed to interpret the oxidation process. When treating real copper-plating wastewater (COD=3,660 mg/L) catalyzed by self-contained 1.4 g/L copper, 98.6% of COD removal was obtained using 0.6 M H₂O₂ in 180 min. In addition to the removal of organic matter, copper complexes were decomposed to form easily removed free copper ions. This study shows that UV/Cu(II)/H₂O₂ is not only a powerful treatment method for COD removal of EDTA wastewater, but also an environmental friendly treatment process for copper-containing organic wastewater.

Keywords: UV/H₂O₂; EDTA; Copper-plating wastewater; Chemical oxygen demand (COD)

1. Introduction

Ethylene diamine tetraacetic acid (EDTA) is a common industrial and domestic water contaminant. It is used as an important decontaminating agent in the nuclear industry. Although EDTA itself is relatively risk-free to public health [1], it can increase the distribution of metals in the environment through the formation of very stable and mobile metal-EDTA complexes [2,3]. EDTA is not easily biodegradable [4] and

hardly adsorbed by activated carbon and resistant to ozone oxidation [5,6]. Therefore, degradation of EDTA has attracted many researchers' attention during the last two decades. Several processes have been developed such as ultrasonic [7], electrochemical oxidation [8], photocatalysis [9,10], and UV/H₂O₂ [11,12].

Transition metals are often used to catalyze redox reactions [13]. Among the transition metals, copper has been found to possess high activity, and therefore, copper and copper-based catalysts have been widely studied [14]. Many researchers have reported the effectiveness of the homogeneous Cu²⁺ catalysts in the

*Corresponding author.

wet air oxidation of organic compounds [15,16]. Rodríguez et al. investigated degradation of methylene blue by catalytic wet air oxidation with Fe and copper catalysts supported on multiwalled carbon nanotubes. They found that the copper catalyst gave higher removal of TOC and color at different temperatures than the iron catalyst [17]. Some researches have compared the iron-based catalysts with copper-based catalysts; the results demonstrated that copper-based catalysts show better catalytic performance, and wider range of pH operations [18,19]. Moreover, with H₂O₂ present, homogeneous and heterogeneous copper catalysts have shown the ability to produce ·OH in a Fenton-like system [20,21]. Therefore, the catalytic activity of copper is greatly enhanced when H₂O₂ is present as the oxidant. However, few attempts were made in the case of addition of UV in the Cu/H₂O₂ process.

Most of the industrial wastewaters contain both toxic heavy metals and refractory organic compounds, such as electroplating wastewater, dyeing wastewater and so on. However, it is difficult to remove heavy metals by precipitation method due to the complexation of heavy metals by organic matter. Therefore, the research of using the heavy metals originally existing in the wastewater as catalyst to remove the refractory organic pollutants is very meaningful. Furthermore, with the removal of the organic pollutants, the heavy metals can be easily reduced by precipitation. Copper ion is one of the most common heavy metal contained in the industry wastewater.

Therefore, based on the above mentioned idea, the objective of this study was to clarify whether organic pollutants, as exemplified by EDTA, could be oxidized by UV/Cu(II)/H₂O₂ process. The effects of the key operating variables, such as H₂O₂ dosage, Cu²⁺ concentration, initial pH, and initial EDTA concentration were studied. The experiment was conducted by changing one variable at a time while keeping other parameters constant. The comparison with the direct UV photolysis and only Cu²⁺ in the presence of H₂O₂ were also studied. In addition, the oxidation effects of organic pollutants in real copper plating wastewater were also investigated.

2. Experimental

2.1. Material and analysis

Copper sulfate (CuSO₄·5H₂O), Disodium EDTA (Na₂H₂EDTA), hydrogen peroxide (30%, w/w), sulfuric acid (98%, w/w) and sodium hydroxide were obtained from Tianjin Chemical (Tianjin, China). All chemicals were analytical grade reagents and were used as received without further purification. Distilled

water was used to prepare all experimental solutions. The copper-plating wastewater was obtained from an electroplating plant in Shenzhen, China. The characteristics of the copper-plating wastewater were listed in Table 1. The pH of the solutions was adjusted with either H₂SO₄ or NaOH in all the experiments. The different concentrations of acid or base have been chosen in order to add the minimum quantity of these species to avoid the volume of the reaction mixture.

Even if EDTA concentration has dropped drastically, some by-products such as ethylenediaminediacetic acid (EDDA), iminodiacetic acid (IDA), and oxalic acid could be formed [12,22–24]. Therefore, in order to test the mineralization degree of EDTA, the degradation effect was reflected by measuring COD which was measured using Standard Method 5220D [25], and possible by-products formed during the EDTA degradation were not monitored. Copper was analyzed by atomic absorption spectroscopy (Shimadzu AA-6300C) using the direct aspiration flame method. The pH was measured by a pHs-25 instrument (Rex Analytical Instrument Co., Shanghai).

2.2. Photoreactor

A lab-scale photoreactor was designed for the batch experiments. The photoreactor had a capacity of 4 liters. The irradiation was provided by a low-pressure mercury lamp (Shenzhen Dohill Inc., 80 W electric power, and 314 cm² irradiation surface) with predominant UV intensity at 253.7 nm (75 mW/cm² at the surface of the lamp). The lamp was vertically located in the center of the photoreactor. During the experiments, compressed air was bubbled from the bottom at a flow rate of approximately 2,500 mL/min to achieve completely mixed batch conditions.

2.3. Experimental procedures

Fourliters of experimental solution was added to the photoreactor in each experiment. Then, initial pH of solution was adjusted to the desired pH by adding 1.0 M sulfuric acid and/or 1.0 M sodium hydroxide. From the beginning to the end of the reaction, predetermined amounts of H₂O₂ was continuously added

Table 1
Characteristics of copper-plating wastewater

Parameters	Value
pH	2.0
TDS (g/L)	19.0
Chemical oxygen demand (mg/L)	3,660
Copper (g/L)	1.4

into the reactor by a peristaltic pump at a desired constant flow rate. At each of appropriate time intervals, a 10-mL sample of the solution was removed from the photoreactor into the tubes for test. Any hydrogen peroxide, present in the samples after UV/H₂O₂ treatment, was quenched using catalase (3,050 units/mg solid, Sigma–Aldrich) extracted from bovine liver. All treated samples were settled for 60 min and diluted for further measurements. Each experiment was performed at least twice, except in the cases where the variation for replicate experiments exceeded 5%, more replications were performed. In order to eliminate the influence of volume changes caused by the added H₂O₂, the COD removal efficiency (R_{COD} in%) was calculated using Eq. (1):

$$R_{\text{COD}} = \frac{\text{COD}_{\text{initial}} \times V_{\text{initial}} - \text{COD}_{\text{sample}} \times (V_{\text{initial}} + V_{\text{H}_2\text{O}_2})}{\text{COD}_{\text{initial}} \times V_{\text{initial}}} \times 100 \quad (1)$$

where R_{COD} is the COD removal efficiency (%); $\text{COD}_{\text{initial}}$ is the initial COD concentration (mg/L); $\text{COD}_{\text{sample}}$ is the COD concentration of the sample (mg/L); V_{initial} is the initial solution volume (L); $V_{\text{H}_2\text{O}_2}$ is the added H₂O₂ volume (L).

All of the experiments and measurements were carried out at room temperature.

3. Results and discussions

3.1. Background experiment

Degradations of EDTA by UV, H₂O₂, UV/H₂O₂, Cu(II)/H₂O₂, and UV/Cu(II)/H₂O₂ were carried out,

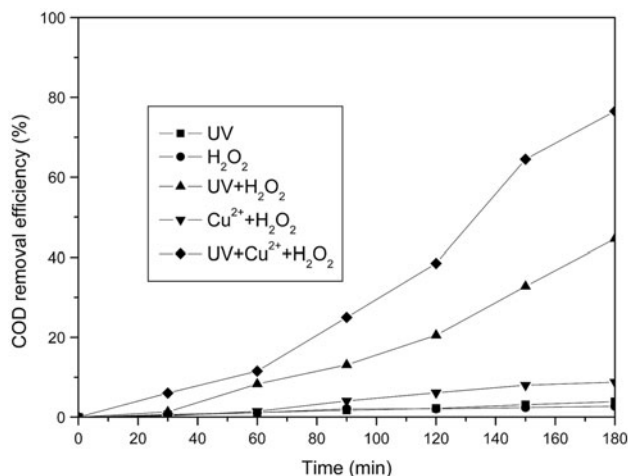
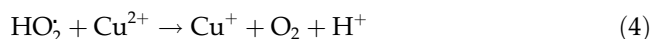


Fig. 1. Degradation efficiency of COD with different processes. Experimental conditions: initial EDTA concentration 5 g/L, H₂O₂ dosage 0.8M, initial pH 3.0 and CuSO₄·5H₂O load 4 g/L.

respectively, and the results are shown in Fig. 1. Single whether UV or H₂O₂ was very negligible to degradation COD of EDTA. There was no apparent COD removal when the solution was treated with Cu(II)/H₂O₂ process in the dark. The UV/H₂O₂ process was also insufficient to achieve excellent oxidation efficiency. However, when the reaction was carried out in UV/Cu(II)/H₂O₂ system, the best COD removal efficiency was observed and could reach up to 76.5%. Results illustrated that the EDTA degradation rate can be accelerated by using UV radiation, which suggested that UV was a key factor in the catalytic degradation process.

In the UV/H₂O₂ process, ·OH can be produced by reaction (2), which is a strong oxidizing agent. However, ·OH can react with H₂O₂ molecules to produce hydroperoxyl radical (HO₂·), which is a weaker oxidizing agent [26]. Therefore, less ·OH was available for oxidation of the organic contaminants. However, the participation of the copper ions could improve the situation. In detail, Cu²⁺ could react with HO₂· to form Cu⁺, which could react with H₂O₂ to form ·OH (reactions 4 and 5) [27]. The kinetics of the UV/Cu(II)/H₂O₂ process was consistent with the following chain mechanism of the photocatalytic decomposition of H₂O₂ [28]:



Therefore, it is believed that ·OH was generated by the UV/Cu(II)/H₂O₂ process, and thus, the EDTA was oxidized by this strong oxidizing agent.

3.2. Effect of H₂O₂ dosage

The effects of H₂O₂ dosage on the oxidation of EDTA have been investigated. Experiments were carried out using different concentrations of H₂O₂ (0.2, 0.4, 0.8, 1.2 and 1.6M), and the results are shown in Fig. 2. The degradation efficiency of EDTA increased with increasing H₂O₂ concentration. However, when H₂O₂ increased beyond a certain value of 1.2M, the degradation efficiency increased insignificantly. At lower concentration, H₂O₂ could not generate enough ·OH and the oxidation rate was limited. With the increase of H₂O₂, the reaction rate was elevated as

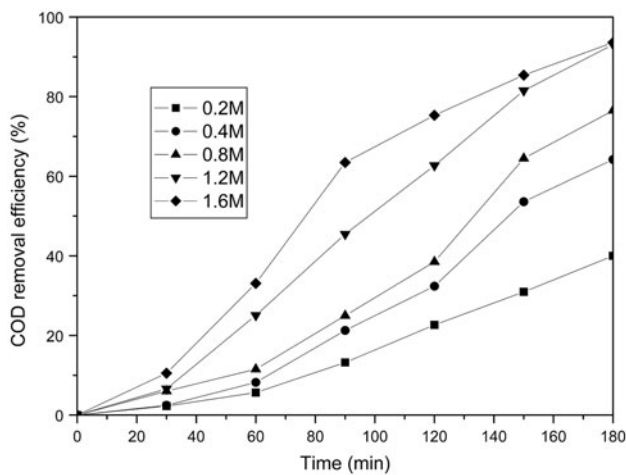


Fig. 2. Influence of H_2O_2 dosage on the degradation efficiency of COD. Experimental conditions: initial EDTA concentration 5 g/L, initial pH 3.0 and $\text{CuSO}_4 \cdot 5\text{H}_2\text{O}$ load 4 g/L.

more OH was formed. However, at higher H_2O_2 concentration, the OH scavenging effect occurred significantly [29]. According to the results, 1.2 M H_2O_2 is the best choice to deal with 5 g/L EDTA solution at initial pH of 3.0 and $\text{CuSO}_4 \cdot 5\text{H}_2\text{O}$ of 4 g/L. 93.1% of COD removal efficiency was achieved in 180 min.

3.3. Effect of Cu^{2+} dosage

The effect of Cu^{2+} was studied using different doses of $\text{CuSO}_4 \cdot 5\text{H}_2\text{O}$ from 2 to 8 g/L with a fixed dose of 0.8 M H_2O_2 (30%, w/v), and the results are shown in Fig. 3. The results indicated that the degradation efficiency of EDTA was significantly influenced by the dosage of Cu^{2+} . With increasing Cu^{2+} dose, COD degradation rate was also increased and the highest rate was achieved at the dosage of 6 g/L $\text{CuSO}_4 \cdot 5\text{H}_2\text{O}$. The reason is that the increase in Cu^{2+} dosage as catalyst can promote more $\cdot\text{OH}$ generation, and thus elevates the degradation efficiency. However, higher copper concentrations (such as 8 g/L $\text{CuSO}_4 \cdot 5\text{H}_2\text{O}$) were found to lead to lower degradation rates. This was in agreement with the results reported in the literature [30]. The possible reason was that higher concentration of Cu^{2+} would increase color degree of the system, and thus decrease light UV penetration in the solution [31].

3.4. Effect of initial pH

To investigate the effect of the initial pH of solution, the experiments in the pH ranging from 2.0 to 11.0 were carried out. Fig. 4(b) indicated that the process was more efficient in the initial pH of 3.0.

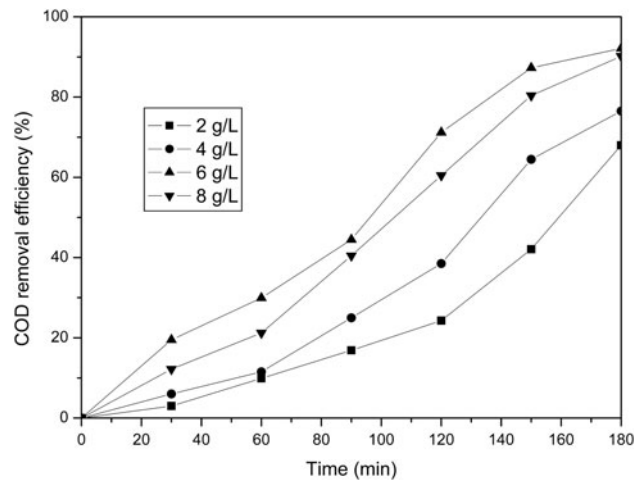


Fig. 3. Influence of $\text{CuSO}_4 \cdot 5\text{H}_2\text{O}$ dosage on the degradation efficiency of COD. Experimental conditions: initial EDTA concentration 5 g/L, H_2O_2 dosage 0.8 M and initial pH 3.0.

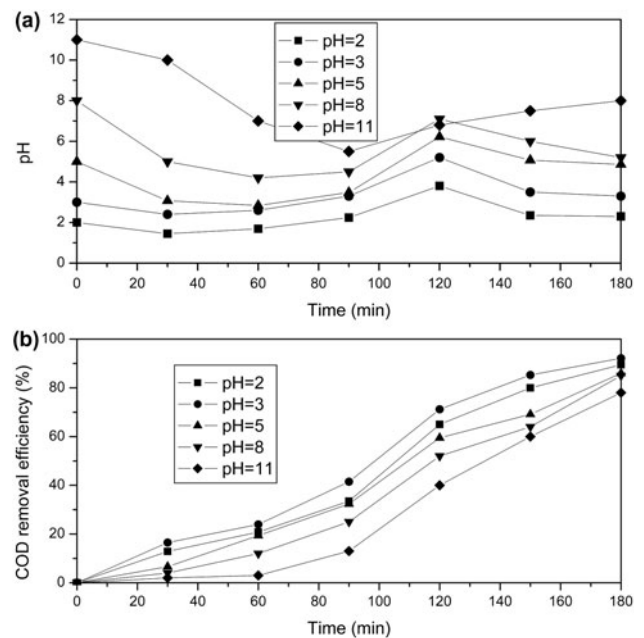


Fig. 4. Changes in the pH for its different initial values (a), and the influence of the initial pH on the degradation efficiency of COD (b). Experimental conditions: initial EDTA concentration 5 g/L, H_2O_2 dosage 0.8 M and $\text{CuSO}_4 \cdot 5\text{H}_2\text{O}$ load 4 g/L.

Under extreme acidic conditions (e.g. pH=2.0), the slower generation of OH from H_2O_2 decomposition lowered the oxidation rates. On the other hand, extreme alkaline conditions (e.g. pH=11.0) also resulted in the drop of oxidation rates. There may be two reasons: firstly, the self-decomposition rate of H_2O_2 (Eq. (6)) increased significantly with increasing

solution pH [32]. Secondly, the formation of cupric hydroxide complexes led to a reduction of copper catalytic activity. Even when the initial pH was up to 8, 80% of COD removal could be achieved at the reaction time of 180 min.



In addition, Fig. 4(a) showed that, pH dropped rapidly in the early stages of the oxidation process. The results can be explained by the formed acidic intermediates, such as EDDA, IDA, and oxalic acid. As further degradation of the acidic intermediates occurred, pH was gradually increased in the later stages of the oxidation process.

3.5. Effect of initial EDTA concentration

The effect of various initial EDTA concentrations on COD removal efficiency has been investigated. Fig. 5 indicated that with the increasing initial concentration of EDTA from 1 to 7 g/L, the COD removal efficiency decreased from 94.61 to 50.10% at the time of 180 min. At higher initial EDTA concentration, with constant photons entering into the solution, the relative concentration of $\cdot\text{OH}$ was lowered, which consequently led to a decreased COD removal efficiency [33].

3.6. Treatment of copper-plating wastewater

Many previous researches have shown the degradation reactions with only synthesized EDTA

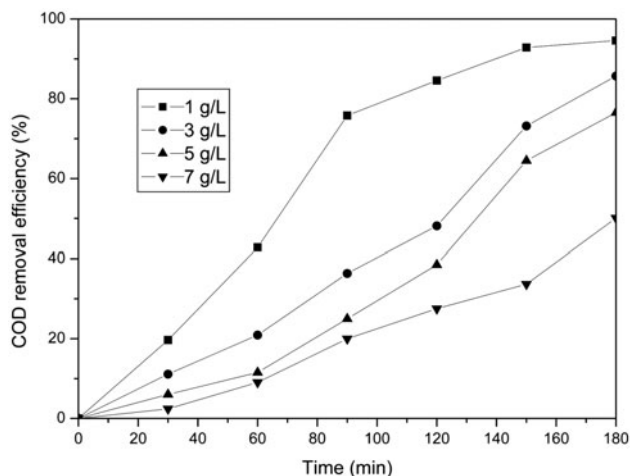


Fig. 5. Influence of initial EDTA concentration on the degradation efficiency of COD. Experimental conditions: H_2O_2 dosage 0.8M, initial pH 3.0 and $\text{CuSO}_4 \cdot 5\text{H}_2\text{O}$ load 4 g/L.

wastewater, but few researches were demonstrated reactions of real wastewater. The real copper-plating wastewater COD removal was compared by four different pH UV/ H_2O_2 processes: 2.0 (original value), 3.0, 8.0, and 11.0, which are catalyzed by the copper ions existing in the wastewater. As in the degradation of the synthesized EDTA, the best COD removal was found in the initial pH 3.0. The result was shown in Fig. 6(b). However, for the treatment of the real wastewater, the similar COD removal efficiency was obtained at the initial pH 2.0 and 3.0. The understandable reason could be easily found from the pH changes during the COD degradation process (Fig. 6 (a)). It shows that, regardless of the initial pH 2.0 or 3.0, the pHs of the solutions both changed in the range of 2.0–3.5 during the treatment process. According to the results, the UV/ $\text{Cu(II)}/\text{H}_2\text{O}_2$ process can effectively remove organic auxiliary chemicals simultaneously contained in the copper-plating wastewater. At the reaction condition of original pH 2.0, H_2O_2 0.6M, copper 1.4 g/L (existing in the wastewater itself), 98.6% of COD removal was obtained in 180 min. In addition to the removal of organic matter, copper complexes were decomposed to form free copper ions, which were beneficial to the subsequent copper removal.

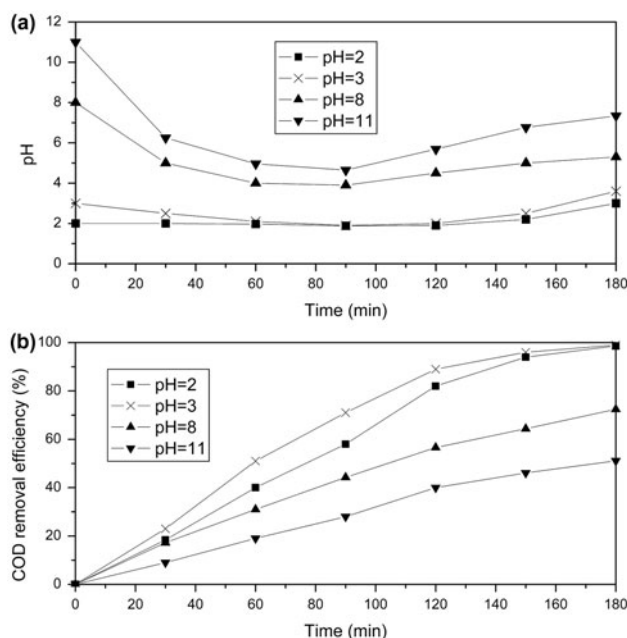


Fig. 6. Treatment of real-copper plating wastewater with UV/ $\text{Cu(II)}/\text{H}_2\text{O}_2$ process at four different pHs. Experimental conditions: COD=3,660 mg/L, H_2O_2 dosage 0.6M and self-contained copper 1.4 g/L.

4. Conclusions

The UV/Cu(II)/H₂O₂ process can be used as an efficient method for the degradation of EDTA and its intermediate decomposition products, revealed by COD removal. The initial pH, initial H₂O₂, and Cu²⁺ dosage significantly influenced the degradation process. It was found that the process was more efficient in the initial pH of 3.0 and either too low (such as 2.0) or too high (such as 11.0) pH would lower the COD removal efficiency. When the initial EDTA concentration was 5 g/L, 93.1% of COD removal efficiency was achieved within 180 min with 1.2 M H₂O₂ and 4 g/L CuSO₄·5H₂O at the initial pH of 3.0. When treating real copper-plating wastewater, catalyzed by copper ions existing in the wastewater (1.4 g/L), 98.6% of COD removal was obtained in 180 min. In addition to the removal of organic matter, copper complexes were decomposed to form easily removed free copper ions. This study shows that UV/Cu(II)/H₂O₂ process is not only a powerful treatment method for COD removal of EDTA wastewater, but also an environmental friendly treatment method for copper-containing organic wastewater.

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